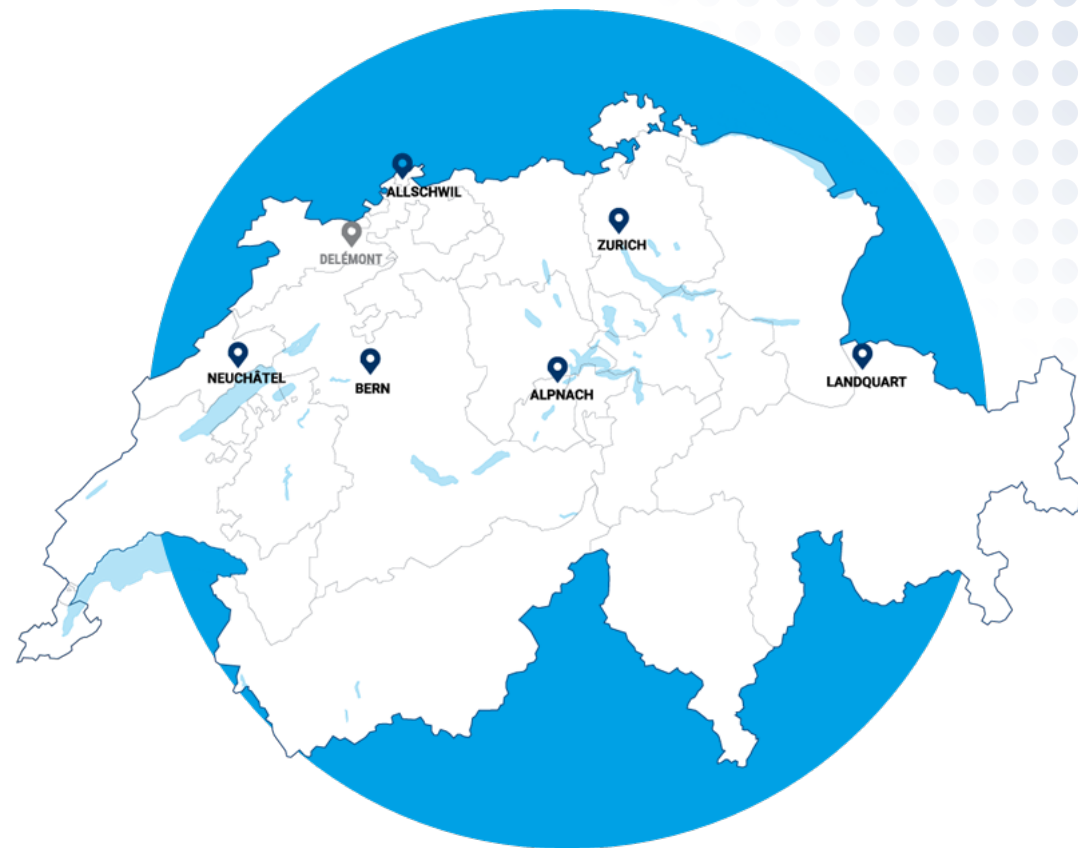


EXPANDED BEAM CONNECTOR FOR DATACOM

CSEM AT A GLANCE

We are a public-private, non-profit Swiss **technology innovation center**

We enable competitiveness by **developing and transferring world-class technologies to the industrial sector**



1984
FOUNDED



630
SPECIALISTS



107.6
M TURNOVER
in 2023



177
PATENT
FAMILIES



> 50
VENTURES
since 1984

WE ARE 100% INDUSTRY-FOCUSED

Staff with industry experience

Long-term support
(80% of staff on permanent contract)

Processes with built-in confidentiality

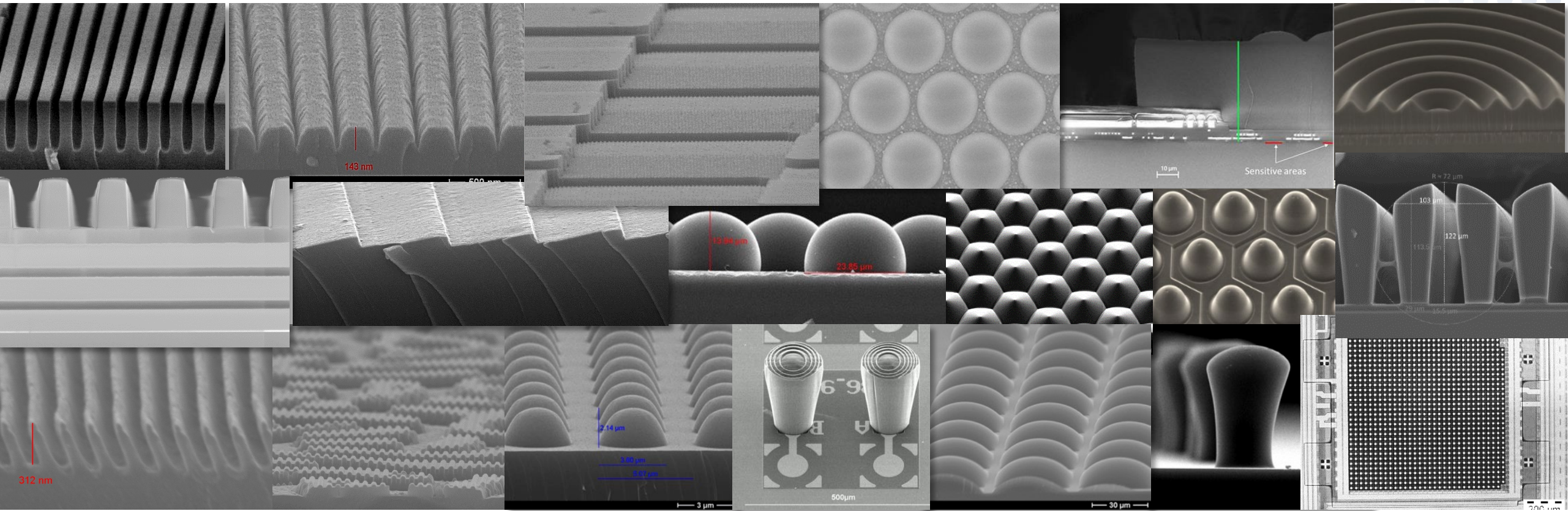


Industrial equipment
(clean rooms, characterization labs)

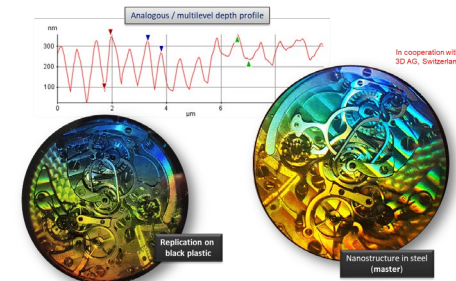
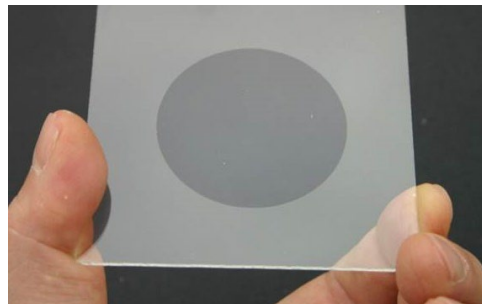
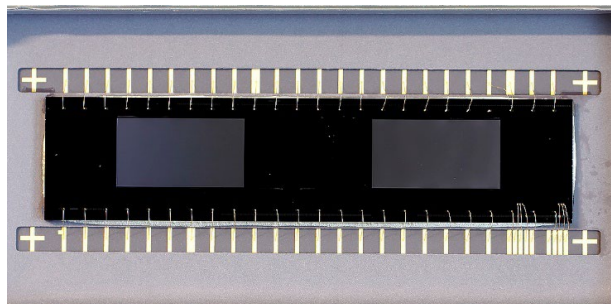
Proven project management methodology
(300 projects/year)

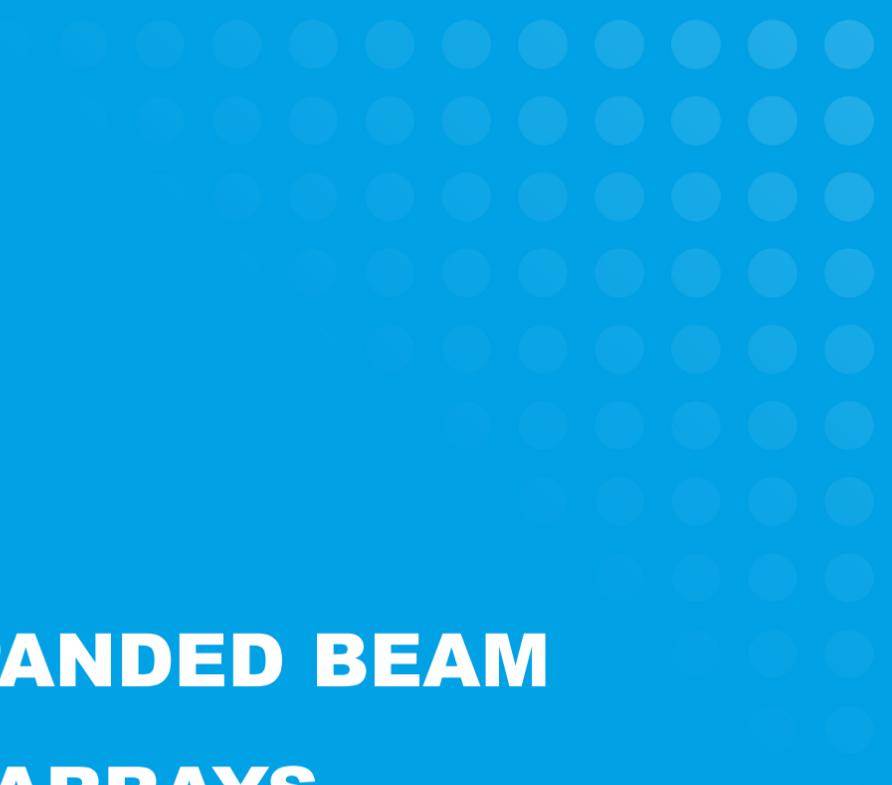
QMS & certifications
(ISO 9001 and 14001,
ISO 13485: Medical devices)

MICRO AND NANO OPTICS MADE AT CSEM



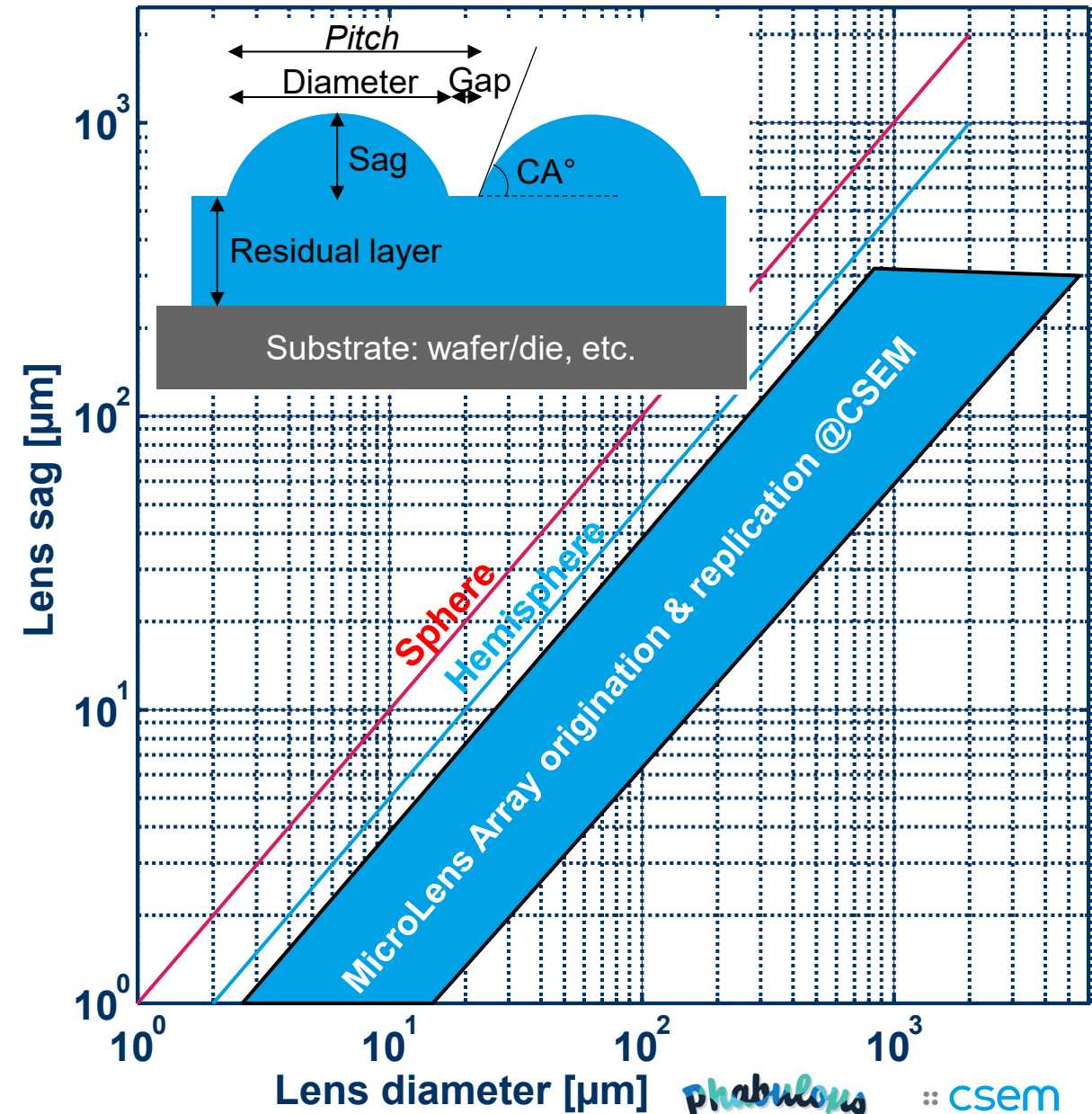
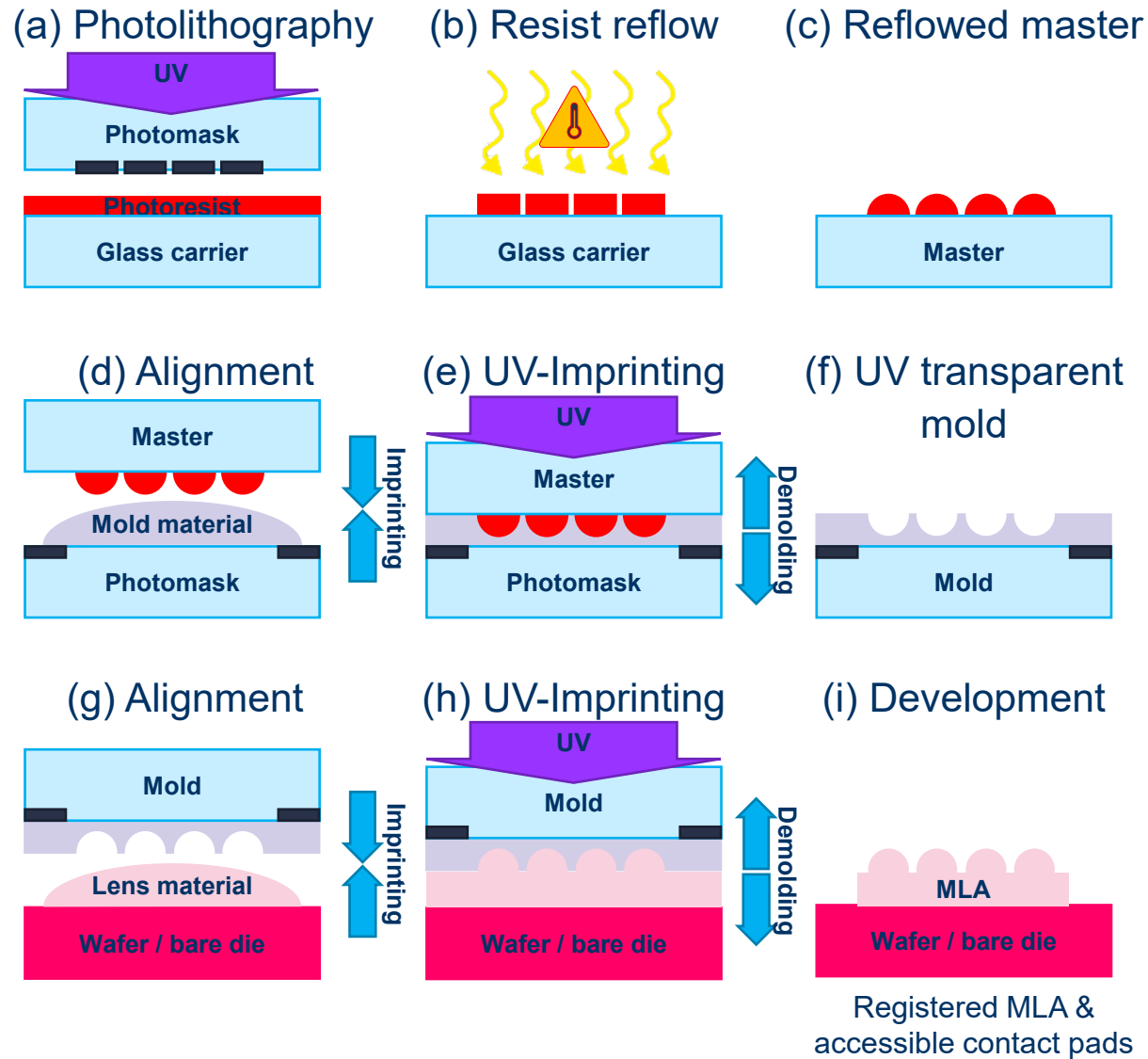
Made on silicon (CMOS etc.), glass, polymer foils, injection molded polymers, metals, ceramics...





**BUILDING BLOCK FOR NEW EXPANDED BEAM
CONNECTORS FOR FIBER ARRAYS**

SPHERICAL MICROLENSSES FULL PROCESS FLOW



SPAD LIGHT CONCENTRATION ON MULTI-PROJECT WAFER/RETICLE → NEED FOR MULTIPLE SAG MLA

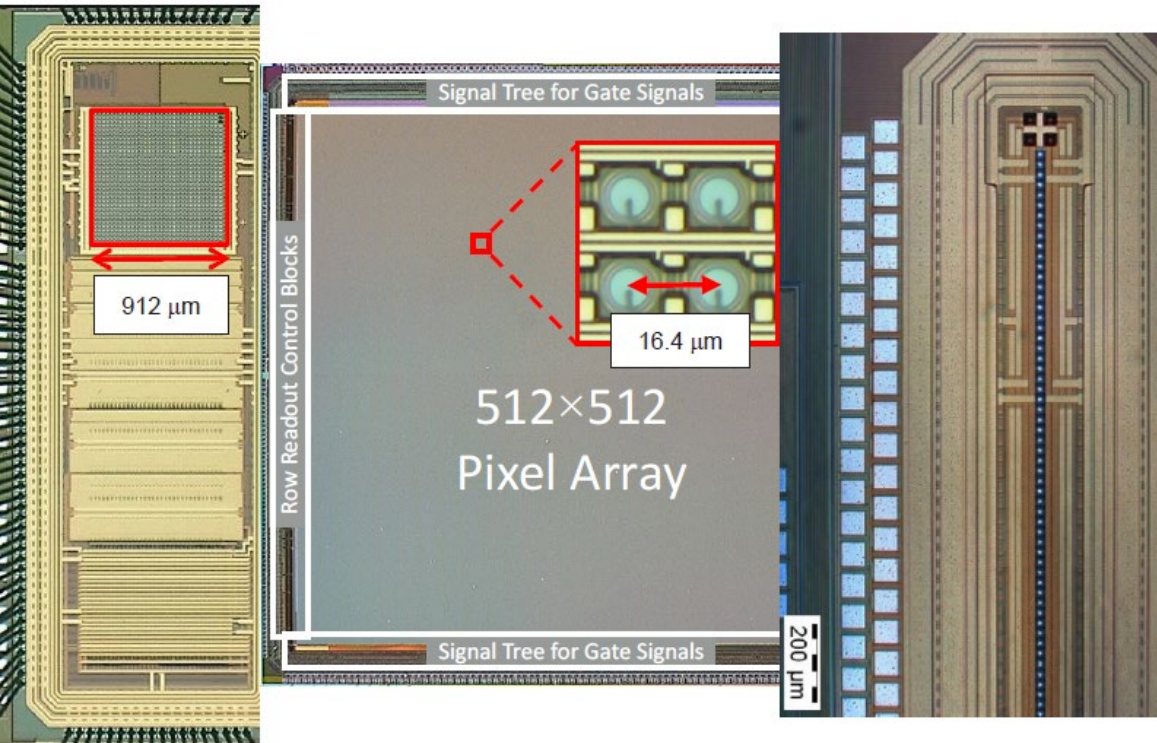
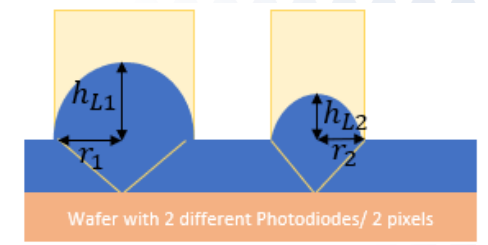
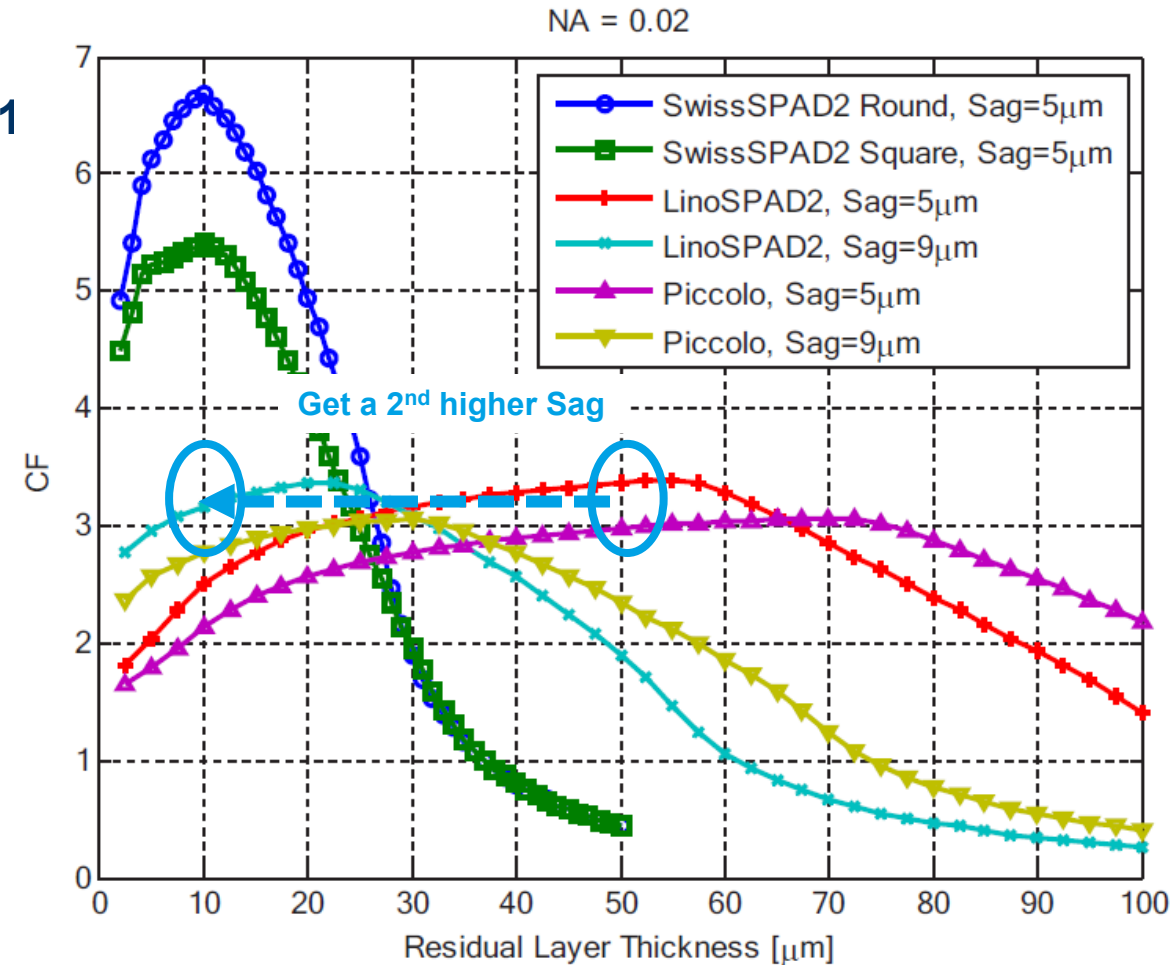


Fig. 1. Micrographs of Piccolo, a 32×32 SPAD array with photosensitive area on the top section, highlighted in red (left) [41,42] – see also Fig. 8 (center); SwissSPAD2 512×512 , a gated SPAD imager with 4 pixels shown in the inset (center, featuring round SPAD active areas in this case) [45]; Detail of LinoSPAD2, a 512×1 linear SPAD array with top alignment cross integrated in the metal stack (right).

Express, 31

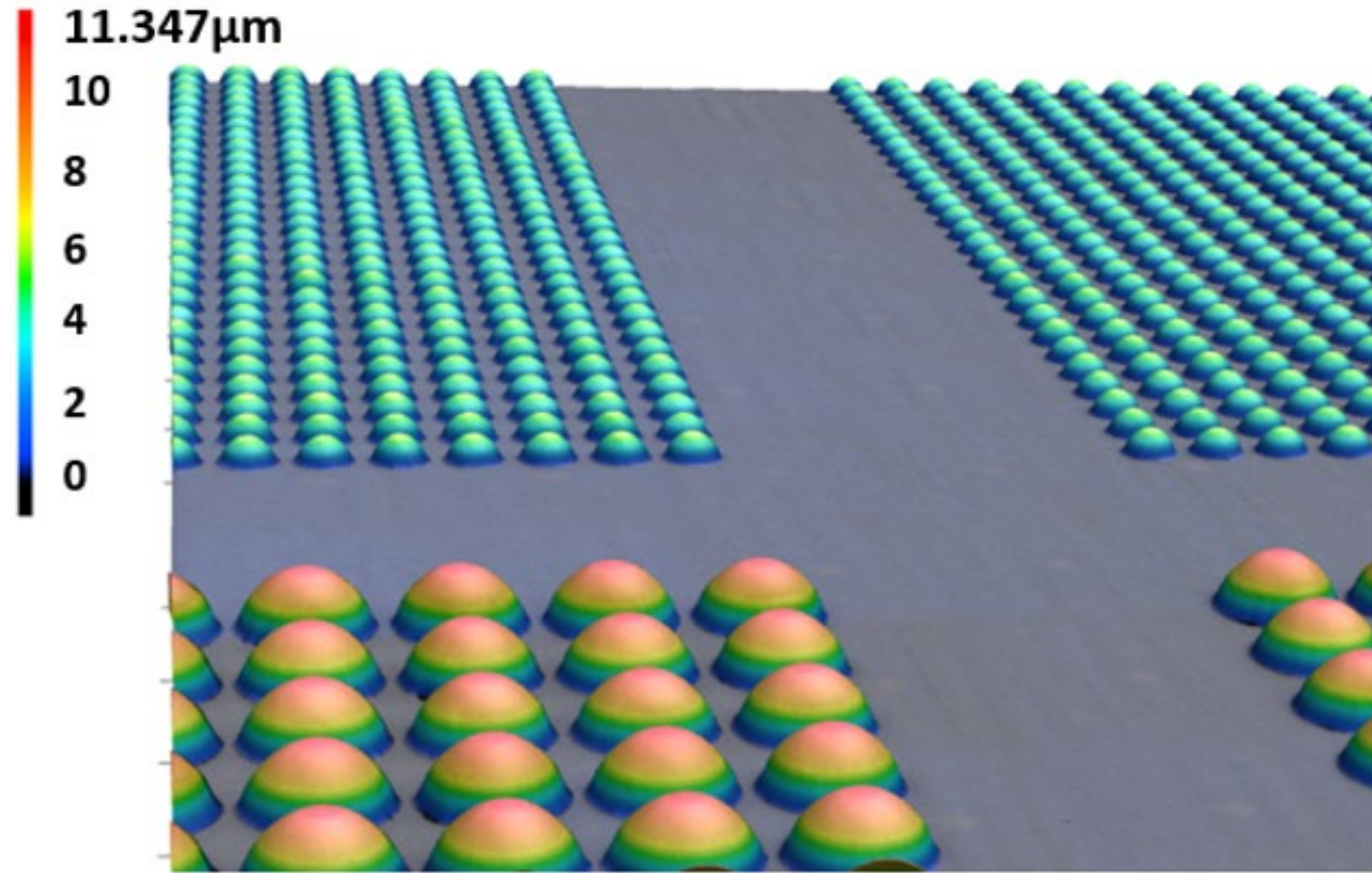
Concentration Factor (CF)



MULTIPLE SAG MLA AT WAFER SCALE

Back MLA: ←
Sag = 6 μm
diameter = 16 μm

Front MLA: ←
Sag = 11 μm
diameter = 34 μm .



PHABULOUS' CUSTOMER WORD

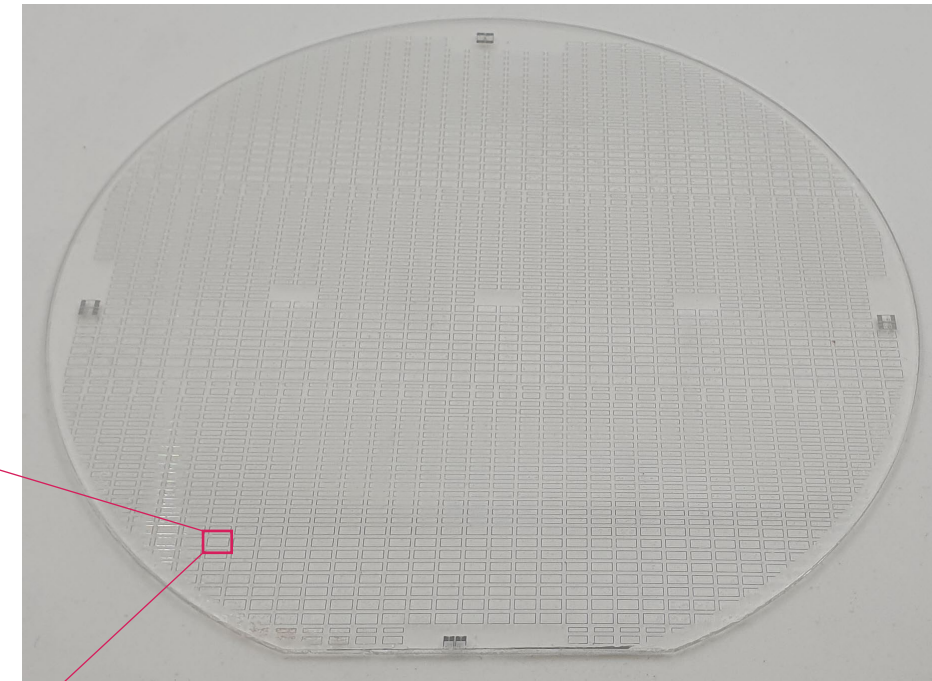
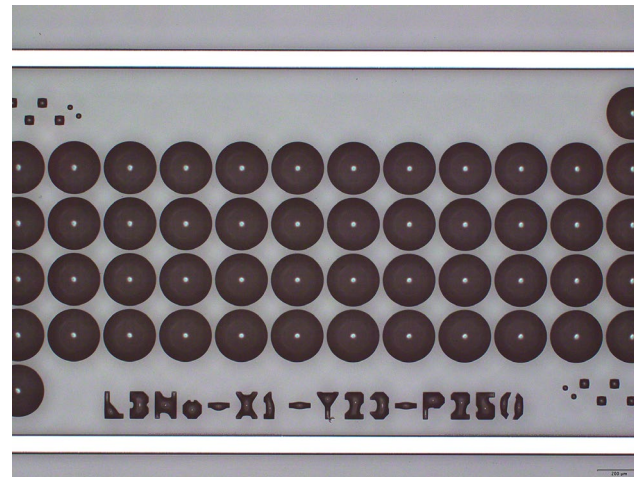
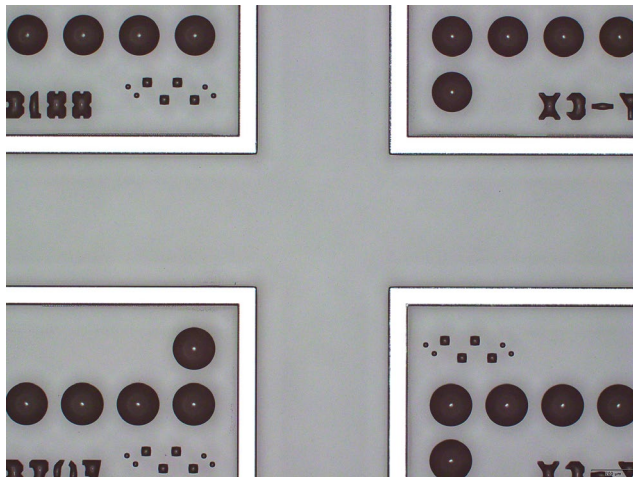
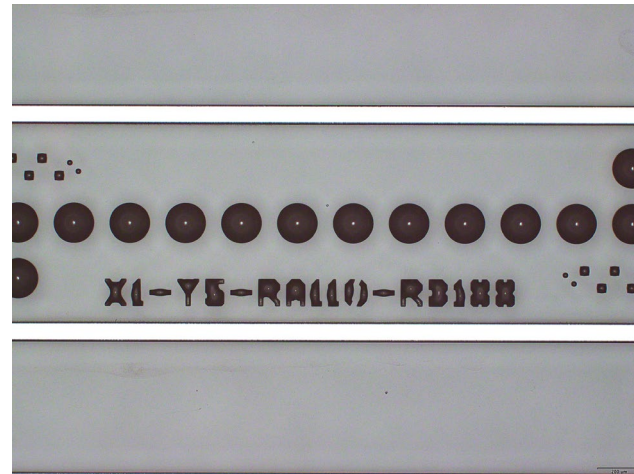
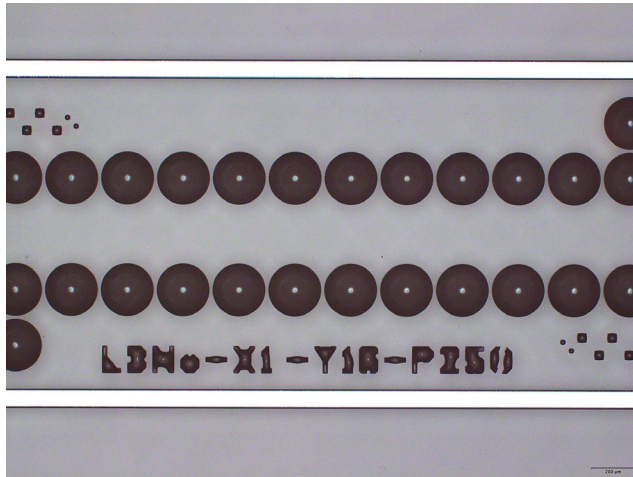
LightBridge
Integrated Photonics Connectivity

Dr Bruno Sfez
Sfez Technologies Ltd



EXPANDED BEAM CONNECTORS FOR DATACOM

MOLD FABRICATION FOR WAFER-SCALE DATACOM EXPANDED BEAM CONNECTORS



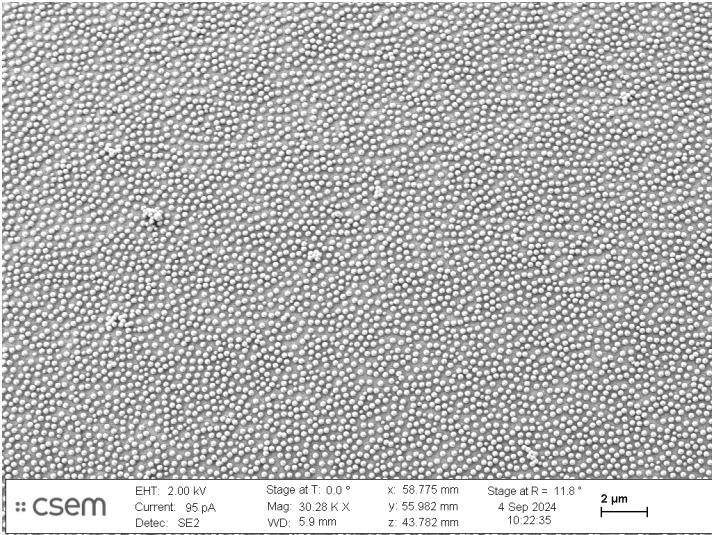
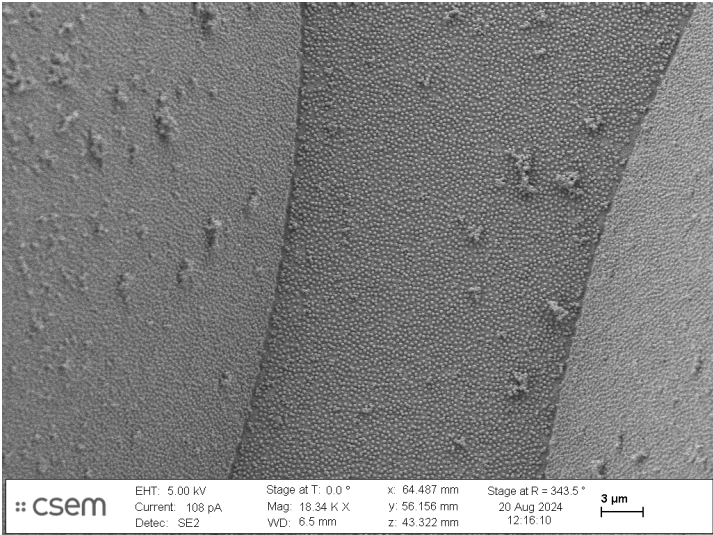
Mold layer

Concave lenses

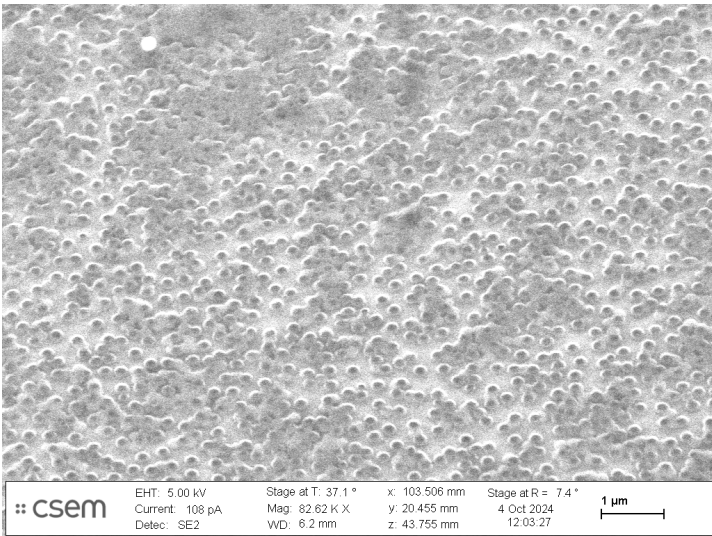
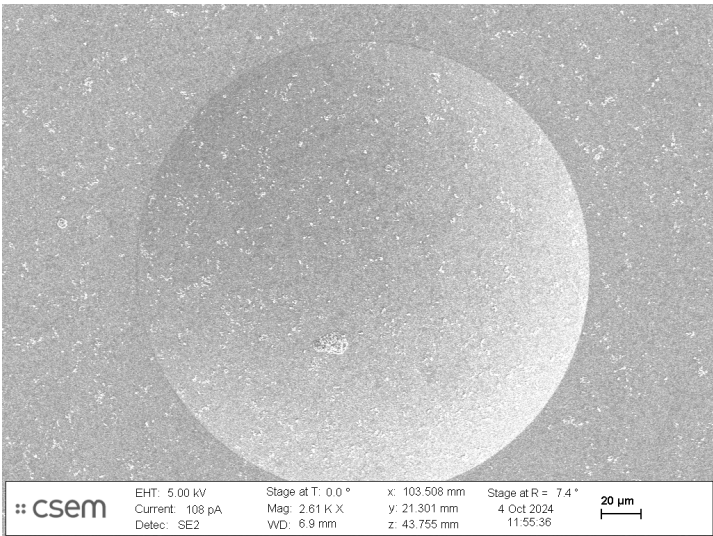
BUILT-IN ANTIREFLECTIVE NANOSTRUCTURES

Process development ongoing. Applicability to selected materials confirmed.

Process step 1



Process step 2



Process being optimized.

SUMMARY AND OUTLOOK

- MicroOptics (wafer level optics) has proven very successful in consumer electronics over the last 2 decades.



- Similar market success have been reached in secured documents (banknotes, passports, ID cards...)
- As seen yesterday, Micro Optics is having more and more use cases and deployment in automotive.
- For many other industries, most optical and photonic systems are not yet miniaturized. Our imagination is the limit to deploy micro-optics in new markets – combined with photonic integrated circuits, small light sources...



TAKE ON CHALLENGES WITH THE RIGHT TEAM

Contact: Daniele Brunazzo -
daniele.brunazzo@csem.ch